

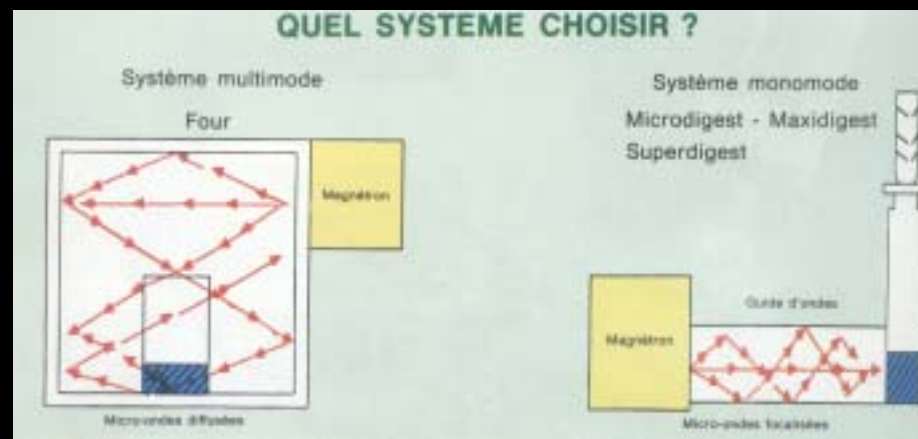
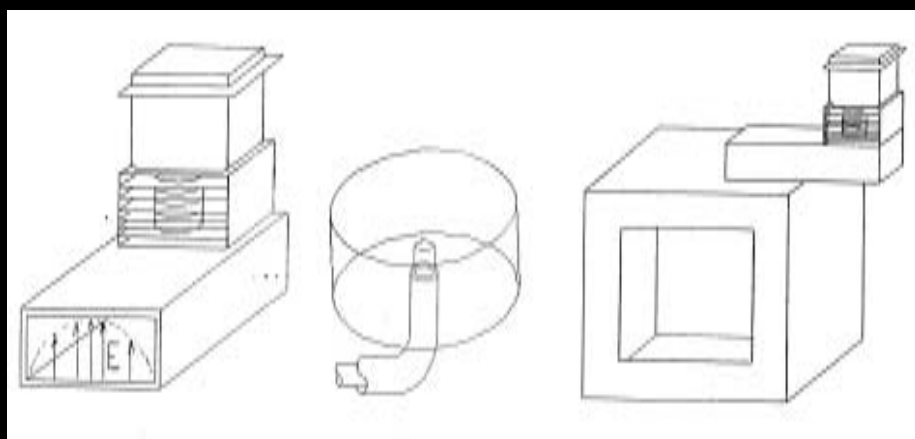
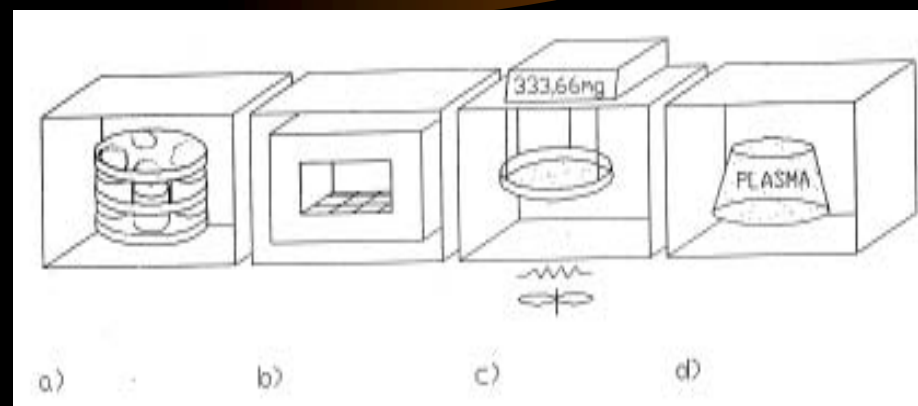
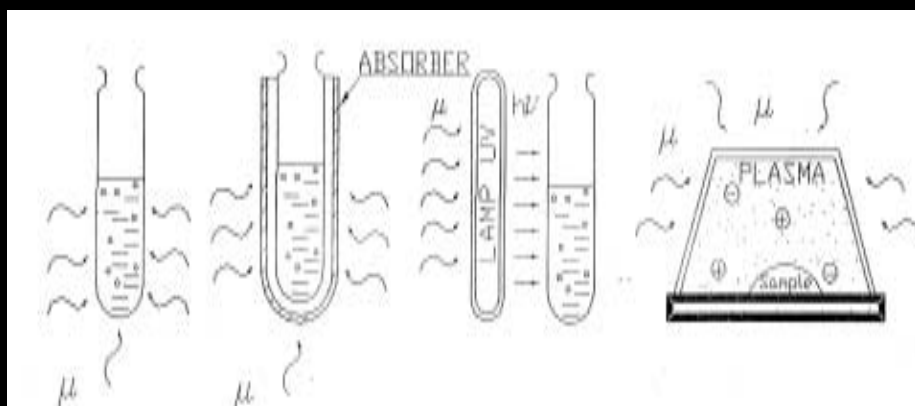
Selmar-GBC Slesin 2004

Mikrofales w akredytowanym laboratorium analitycznym

Edward Reszke
ERTEC-Poland

May 2004

Mikrofale w laboratorium



Just for the beginning

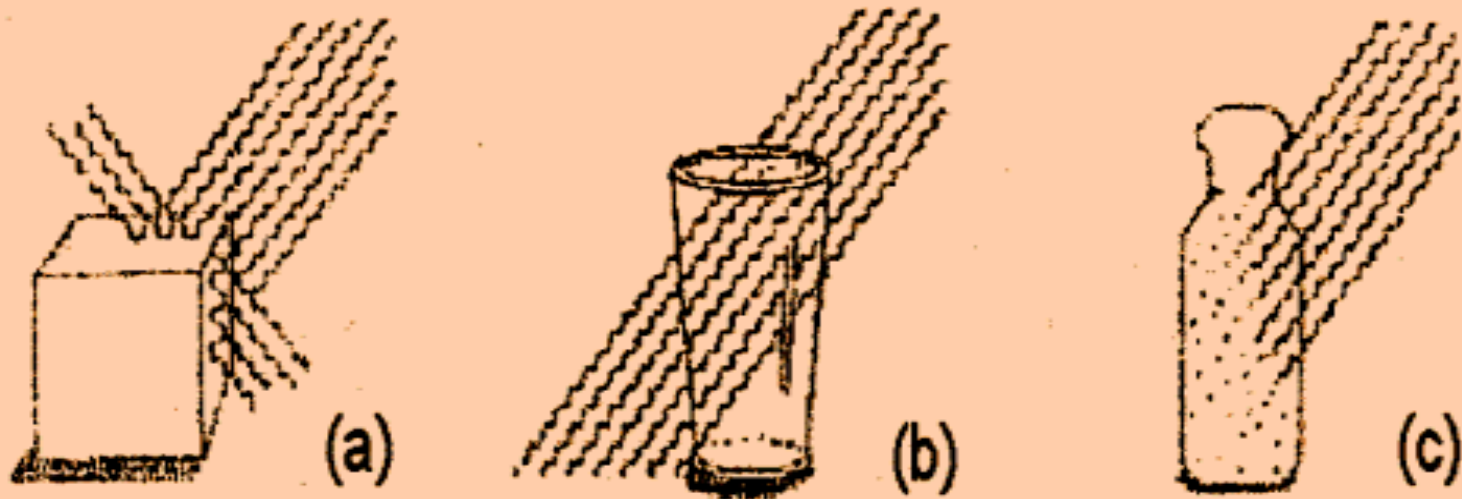


Fig. 2. Interaction of materials with microwaves

- (a) conductor - reflects microwave energy
- (b) insulator - transparent to microwave energy
- (c) dielectric - absorbs microwaves

Piec mikrofalowy Milestone'a



Dry ashing of analytical samples

Why you need a Milestone Pyro Ashing System

REDUCED ASHING TIMES: FROM HOURS TO MINUTES

Sample	Microwave Ashing Temperature (°C)	Microwave Ashing Time (minutes)	Traditional Ashing Time (minutes)
Pet food (ground)	575	21	90
Cat food	575	15	100
Polypropylene	650	22	80
PVC	900	15	120
Polyester	600	15	480
Polyurethane	900	15	120
Coal standard AR2782	750	20	120
Dried eggs yolk	925	25	240
Activated Coal	750	25	180
Flour	900	50	160
Salami	600	60	100

Spopielarka plazmowa firmy Orbis Technologies Ltd



Karma dla zwierząt	ok. 10 godz.
Próbki krwi	2-4 godz.
Trzcina cukrowa	ok. 4 godz.
Kakao	10-12 godz.
Filtr	1-2 godz.
Siano, trawa	10-12 godz.
Liście	4-8 godz.
Wątroba	ok. 12 godz.
Nasiona dyni	8 godz.
Olej sałatkowy	ok. 20 godz.
Mąka pszenna	2-3 godz.
Papierosy	ok. 1 godz.
Detergent – proszek	ok. 15 godz.
Grafit	3-4 godz.
Tkanina nylonowa	3-5 godz.
Papier	1-2 godz.
Włókna poliamidowe	2-3 godz.
Granulat poliamidowy	6-8 godz.



Orbis-parametry pracy

Poliester	ok. 3 godz.
Polietylen	ok. 25 godz.
PVC	ok. 20 godz.
Próbki gleby	5-15 godz.

Komitet Techniczny ISO/TC-146 : *Jakość powietrza: Powietrze atmosferyczne. Oznaczanie włókien azbestowych. Metoda transmisyjnej mikroskopii elektronowej z pośrednim przeniesieniem próbki (2003).*

Urządzenia do spopielenia próbek azbestu w mikrofalowej plazmie tlenowej

Edward Reszke¹⁾, Marta Rożkowicz²⁾

- 1) *Ertec-Poland 54-440 Wrocław ul. Rogowska 146/5 www.ertec.pl, ertec@wp.pl*
- 2) *Główny Instytut Górnictwa, 40-166 Katowice Plac Gwarków 1 soxmr@gig.katowice.pl*

Celem komunikatu jest przedstawienie projektu budowy pierwszego polskiego spopielaacza plazmowego. Projekt dotyczy urządzenia do plazmowego spopielenia całych filtrów z estru celulozy o wielkości porów 0,8 μm i średnicy Ø 25 mm wraz z próbką zawierającą włókna azbestu. W celu wykonania badań prototypu nawiązano współpracę badawczą pomiędzy firmą Ertec a Głównym Instytutem Górnictwa, który podjął się przebadania i optymalizacji charakterystyk nowego przyrządu przy pracy z próbkami laboratoryjnymi materiałów azbestowych o różnych matrycach, czyli badań niezbędnych do atestacji nowego aparatu jako legalnego przyrządu laboratoryjnego spełniającego normy europejskie.

Przygotowywanie prób mikroskopowych materiałów zawierających azbest jest problemem, który pojawił się dopiero w ostatnich latach. Nowa analiza wymaga odkrywania struktury niebezpiecznych włókien azbestu i ich rozróżniania w masie

Prototyp plazmowej spopielarki próbek azbestowych



Wnęka prototypowej spalarki





**Widok podajnika
próbki**

**(filtr celulozowy z
ACM)**

Najnowsze źródło wzbudzenia MIP z wnęką typu TEM



An example of MW system with integrated power source, coaxial feeder and two stub tuner placed between MW generator and applicator (a microwave cavity with TEM mode for MIP excitation)

Otwarte systemy mineralizacji „na mokro”



Maxidigest MX350
Prolabo



Star 2
CEM

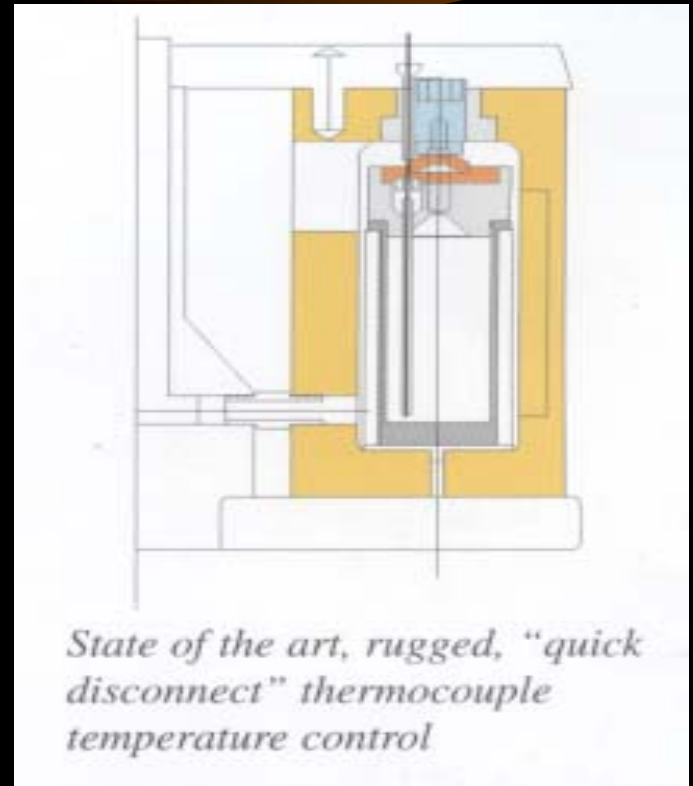


UniClever BM-10
Plazmatronika

High pressure MW systems



Ethos plus
from Milestone



State of the art, rugged, "quick disconnect" thermocouple temperature control

digestion vessel
Ethos

High pressure system



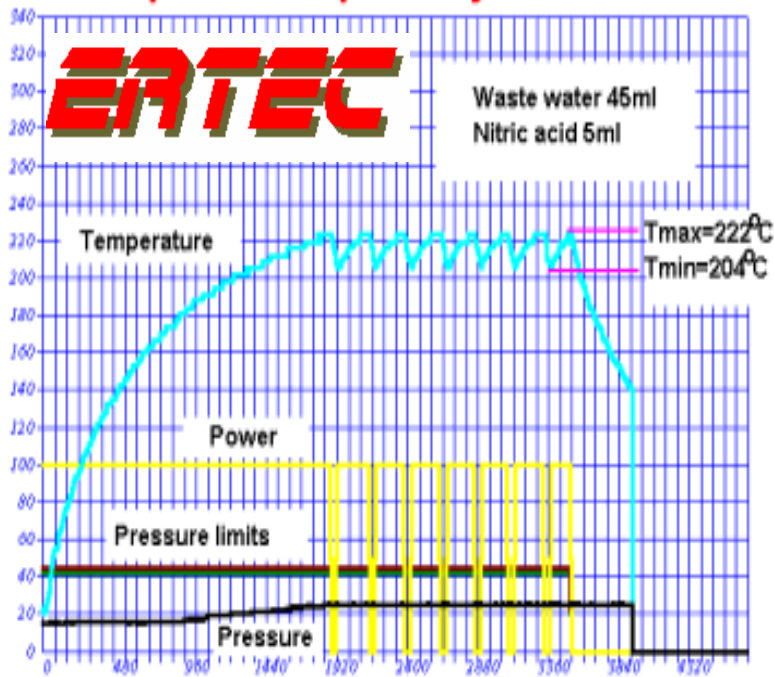
**Plazmatronika-
Nano 2000**



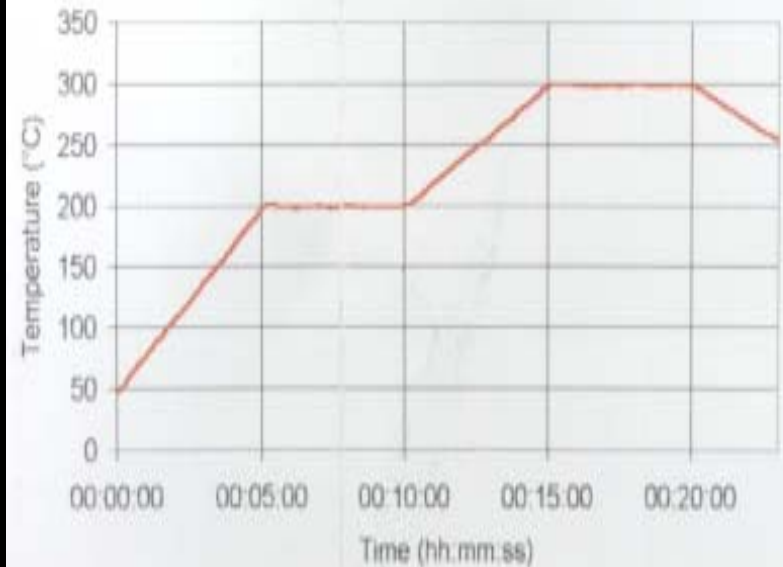
Reactor/mineralizer Ertec

Temperature measurements

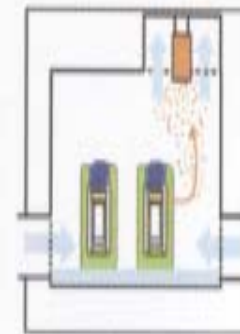
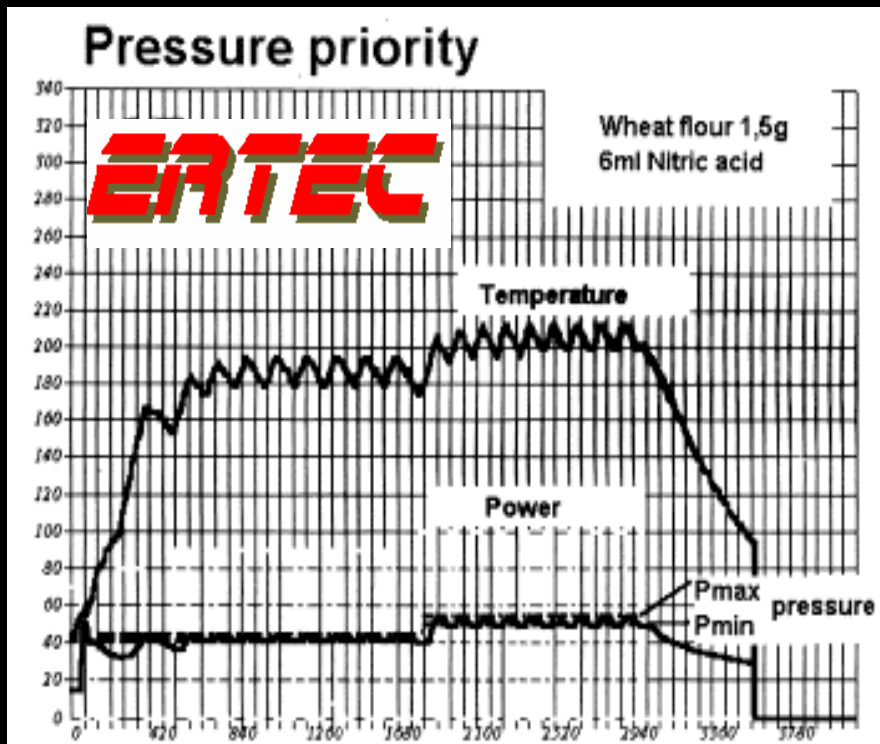
Temperature priority



HPR-1000/10S with ATC-400
Vessel loading 8ml H₂SO₄ + 2 ml H₂O



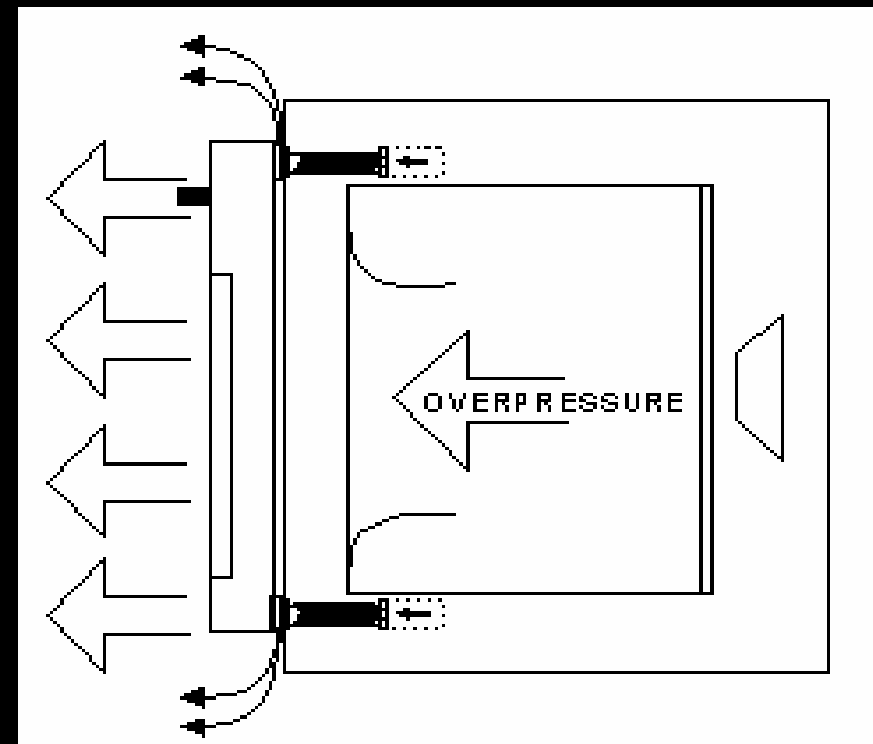
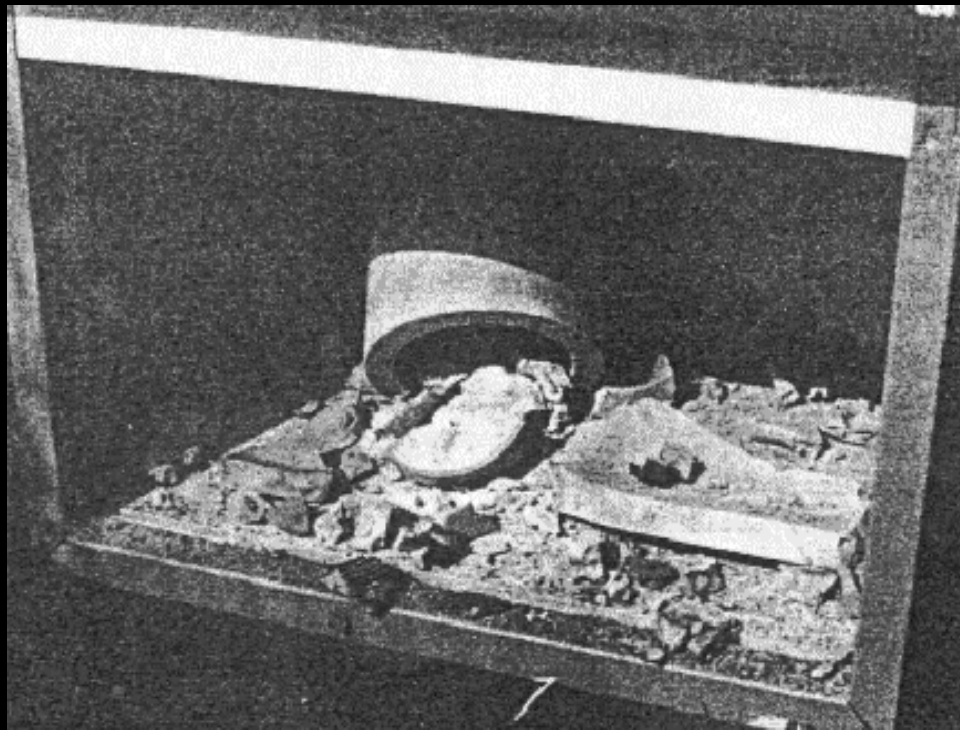
Measurement and control of pressure



QP for pressure limit control
Another first from Milestone's R&D Department. This unique sensor continuously monitors the level of acid vapors in the microwave cavity.

Once over a preset level, the sensor automatically responds by adjusting the microwave power. All vessels in the cavity are monitored simultaneously and independently to effectively limit the pressure in each vessel, thereby preventing overpressure and venting.

Bezpieczne konstrukcje



Rozpuszczanie materiałów nieorganicznych

Table 7. Dissolution speed of „conventional” and microwave closed approaches

Matrix	Conventional Teflon bomb		Microwave digester
	(h)	(min)	(min)
Al ₂ O ₃	24	1440	20
AlN	2	120	15
BN	5	300	15
Si ₃ N ₄	6	360	15

Digestion efficiency

Table 5 Effective of destruction of the organic matrix in the study systems decomposition

Cert.Ref Material	Microwave System	CRM-total C [%]	Degree of C removed C [%]	RSD of RCC [%]
Pig Kidney 186	Paar Physica	48,96	99,25	35,9
	MLS MEGA		97,54	39,7
	Prolabo T		98,93	21,4
	Prolabo S		94,25	40,8
Dogfish DORM 2	Paar Physica	44,20	98,87	34,2
	MLS MEGA		97,07	27,6
	Prolabo T		98,70	35,0
Mussel Tissue 278	Paar Physica	43,88	99,01	32,4
	MLS MEGA		97,70	42,6
	Prolabo T		99,21	10,0
Brown Bread BCR 191	Paar Physica	45,60	99,08	28,9
	MLS MEGA		97,14	31,8
	Prolabo T		98,94	11,4
Aquatic Plant BCR 60	Paar Physica	37,82	98,92	30,9
	MLS MEGA		97,65	34,1
	Prolabo T		98,87	22,6
	Prolabo S		95,11	38,7

RCC - residual carbon content

Digestion reagents

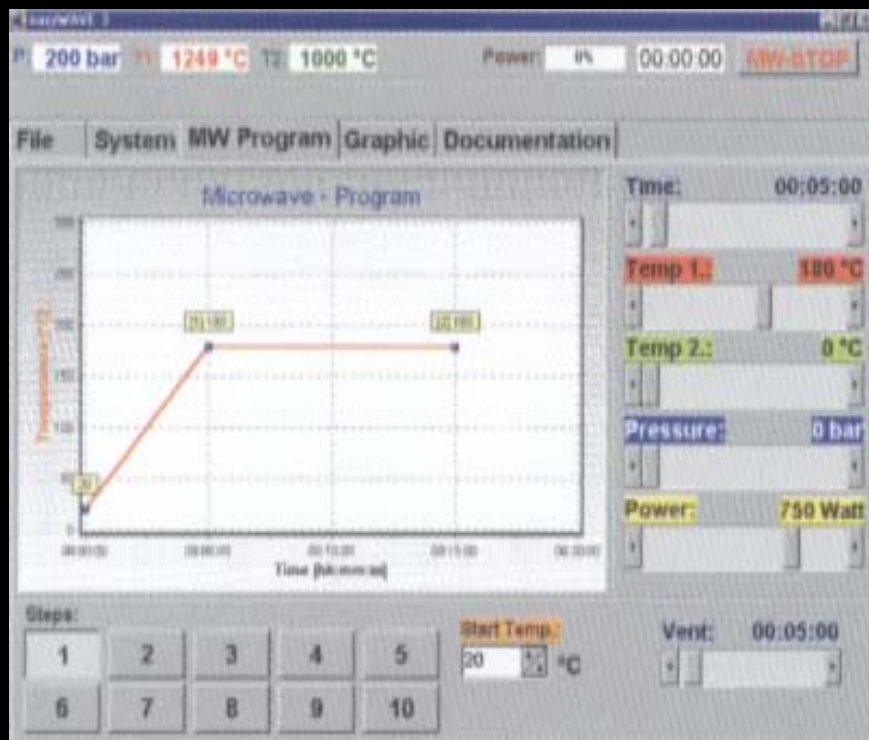
Solution of reagents	Matrix	Uwagi
HNO_3	Biological materials	incompletely digestion at atmospheric pressure
$\text{HNO}_3 + \text{H}_2\text{O}_2$	Biological materials	Effective digestion of small samples
$\text{HNO}_3 + \text{H}_2\text{SO}_4$	general use	Frequently used but promotes losses of easily volatile elements such as As, Ge, Hg, Se
$\text{HNO}_3 + \text{HCl}$	general use	aqua regia
$\text{HNO}_3 + \text{HClO}_3$	Biological materials	High oxidation potential, low loss of As, Hg, Se, In and so on .., safe
$\text{HNO}_3 + \text{HClO}_4$	Biological materials	Effective decomposition , low loss of Pb
$\text{HNO}_3 + \text{HCl} + \text{HF}$	general use	-
$\text{HNO}_3 + \text{HF}$	general use	-
$\text{HNO}_3 + \text{HClO}_4 + \text{H}_2\text{SO}_4$	general use	Temperature regime must be controlled , loss of As, Hg, Fe Sb
HF	inorganic materials	-
$\text{H}_2\text{SO}_4 + \text{HClO}_4$	general use	Small samples , danger of explosion
$\text{H}_2\text{SO}_4 + \text{H}_2\text{O}_2$	general use	Losses of As, Hg, Ge, Ru, Se and many other volatile elements
HClO_4	Biological materials	Strong oxidizer, danger of explosion
$\text{H}_2\text{O}_2 + \text{Fe}^{3+}$	Biological materials except oils, fats and grees	Decomposition with OH^* radicals, low temperature of decomposition, good for large samples, no loss of elements

Material of digestion vessels, memory effects



Material	Melting point	Maximal . T[°C]	tg x10 ⁴
Teflon PFA	302	260	2,1
Teflon FEP	252-262	204	2,1
Halon PTFE	320	260	2,1
Polymethylpentane	240	175	2,1
Polyethylene	120-135	71-93	2,2-2,3
High press.polyethylene	146	121	2,25
Polypropylene	168-171	100-105	2,24-2,4
Polystyrene	242	82-91	2,7-3,1
Polycarbonate	241	121	2,9
NYLON 6	216	102	3,4
Quartz glass	1665		3,8-4,1
Borosilicat.glass	1080		6,3-6,8
Phenol resin	rozkladaju sa	120-190	4,1-5,0

Software and data acquisition



The screenshot shows a control panel window titled 'Total Lab All- Johny'. It contains several sections for process control:

- Etap procesu**: Three radio buttons, with the first one selected (green).
- Program**: A digital display showing '1 10 0 1' with up/down arrows for each digit.
- Krok**: A circular indicator with the number '1' inside.
- Grzanie [mm:ss]**: A digital display showing '0 5' with up/down arrows.
- Moc [%]**: A digital display showing '99' with up/down arrows.
- Pauza [mm:ss]**: A digital display showing '0 5' with up/down arrows.
- Ciśnienie max | min**: A digital display showing '45 42' with up/down arrows.
- Uruchomienie / Zatrzymanie**: A large button labeled '472x479 Start/Stop'.

At the bottom, there is a green text box with the following text:

Okno sterownika programowego - umożliwia sterowanie urządzeniem zgodnie z ustaloną w niniejszym oknie procedurą procesu.

Digestion of difficult organic samples with dry mass over 1g

ERTEC

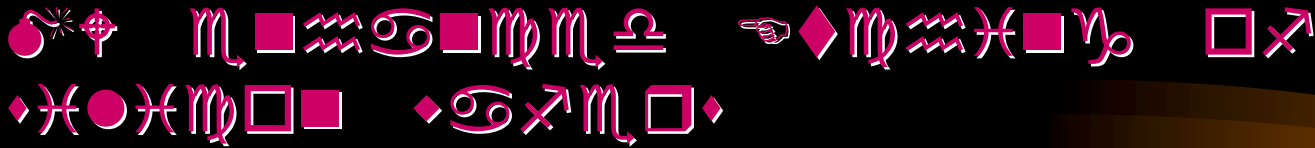
Sample	Mass [g]	Reagents [ml]	Digestion procedure power [%] pressure set. [at]	Pressure reached (oscillation) [at]	Total digestion time [min]
Green coffee	1,5	6 HNO ₃	5'/60% 20-17at; 5'/100% 45-42at 10'/0%	45 (45-42)	20
Tea fix	1,5	6 HNO ₃ , 2 H ₂ O	5'/60% 20-17at; 5'/80% 45-42at; 10'/100%	45 (45-42)	20
Rice	2,5	8 HNO ₃ , 4 H ₂ O	10'/60% 20-17at; 10'/0% 45-42at; 10'/0%	105 (45-42)	30
Goulash soup	1,5	8 HNO ₃ , 4 H ₂ O	10'/60% 20-17at; 10'/100% 45-42at; 10'/0%	74 (45-42)	30
Dry mushrooms	2	8 HNO ₃ , 4 H ₂ O	10'/60% 20-17at; 10'/100% 45-42at; 10'/0%	45 (45-42)	30
Peanut	1,5	8 HNO ₃ , 4 H ₂ O	10'/60% 20-17at; 10'/100% 45-42at; 10'/0%	45 (45-42)	30
Poppy seed	2	8 HNO ₃ , 4 H ₂ O	10'/60%; 10'/100%; 10'/0%	82 (45-42)	30

Efficiency of digestion systems

Dzienna zdolność przerobowa różnych systemów do mineralizacji			
Rodzaj próbek	Masa próbki (sucha)	Wysokociśnieniowy system modułowy [2 moduły]	Systemy mikrofalowe z wnęką wielomodową (6 stanowisk)
Organiczne	do 0,5 g	64 próbek dziennie	48 próbek dziennie
	do 1 g	48 próbek dziennie	zwykle niemożliwe
	do 2 g	24 próbek dziennie	niemożliwe
	do 5 g	12 próbek dziennie	niemożliwe
Nieorganiczne	do 0,5 g	32 próbek dziennie	30 próbek dziennie
	do 1 g	24 próbek dziennie	18 próbek dziennie
	do 2 g	12 próbek dziennie	czasem niemożliwe
	do 5 g	6 próbek dziennie	niemożliwe
Mieszane	do 0,5 g	48 próbek dziennie	36 próbek dziennie
	do 1 g	36 próbek dziennie	24 próbek dziennie
	do 2 g	18 próbek dziennie	zwykle niemożliwe
	do 5 g	10 próbek dziennie	niemożliwe

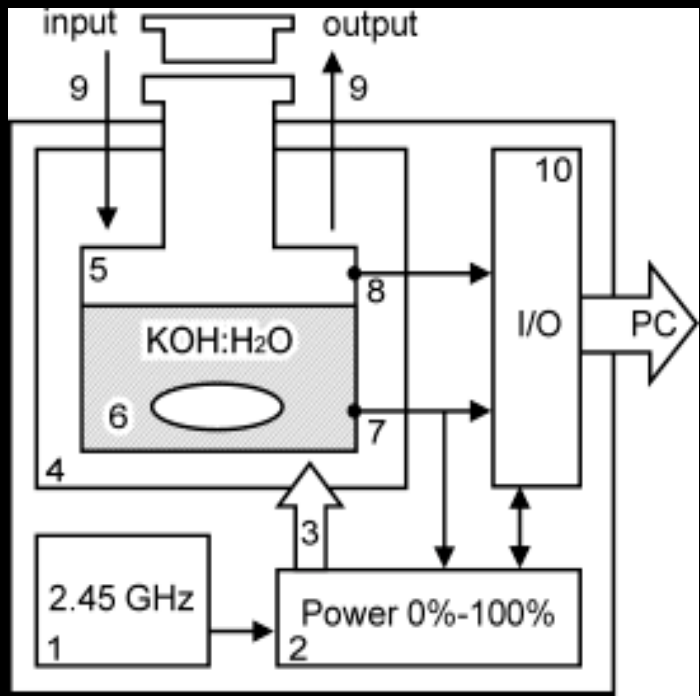
MW vs Conventionally driven reactions

Kind of reaction:	MW reactor		Conventional	
	yeld	time	yeld	time
Dielsa-Alder Condensation (antracen with dimethyl ester of fumarine acid)	87%	10m in	67%	4h
Cyclocondensation reaction - synthesis of piryimidobenzimidazolics - synthesis of derivatives of cumarine	38-86%	15-30m in	brak	48h
	75-90%	1-10m in	60-90%	6h
Reformation of Claisen aromathical alkilic ethers	100%	90s	100%	12m in
Alkilation of salts of carboxylic acids - production of octyl acetat - production of hexadecyl acetat	99%	2m in	2%	2m in
	96%	2m in	brak	20h
Reakcje o-alkilation with alkilic dihalogens	80-90%	5m in	90%	30m in
Cation Reformation , pinakolin reformation after adsorption of pinakol onto montmorylonit	99%	15m in	99%	15h
Oxidation reactions - oxidation of I- and II-order alcohols leading to aldehydes and ketons in the presence of MnO ₂ - oxidation of I- and II-order alcohols to acids and ketons against H ₂ O ₂ - epoxidation of double bonds against H ₂ O ₂	50-80%	3-7m in	25-40%	11h
	60-97%	10-20m in	83-96%	4h
	91-98%	100m in	54-65%	100m in
One-step precipitation of magnetite	100%	10 m in	100%	60 m in
Precipitation of zirconia powders	100%	20 m in	100%	240 m in
Precipitation of zink oxides	100%	3 m in	90%	40 m in



Novel method, named EMSi (Etching Microwave Silicon) a Teflon® reaction vessel containing silicon substrates immersed in the 3 - 5 M KOH solution is positioned inside the microwave resonator and irradiated by 2.45 GHz microwaves. Etching rates for (100) planes: V_{100} equal to $5 \div 10 \mu\text{m}/\text{min}$, in almost cold ($60^\circ\text{C} \div 70^\circ\text{C}$) solutions have been obtained. New, microwave enhanced etching of silicon enabled fast fabrication of the 3D silicon micromechanical structures.

EMSi etching: a) scheme of the stand: 1-microwave generator, 2-power supply unit, 3-connector, 4-single or multimode resonator, 5-reaction chamber, 6-silicon substrate, 7-temperature sensor, 8-pressure sensor, 9-cooling water, 10-I/O, b) process characteristics: pressure, microwave power and temperature versus time.



All stainless steel reactor for etching experiments



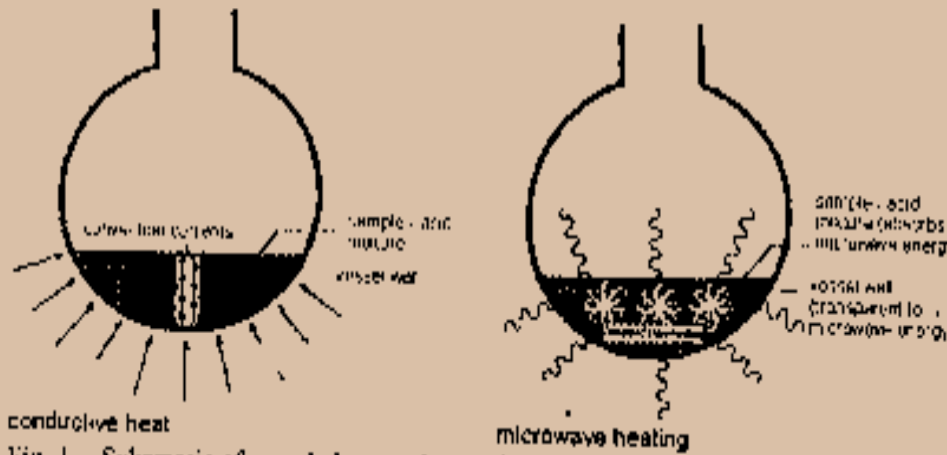


Standard procedures	Microwaves enhanced
low etching rates $V_{(100)} \approx 1 \mu\text{m}/\text{min}$ at 80°C	high etching rates $V_{(100)} \leq 10 \mu\text{m}/\text{min}$ at 80°C
etching rates depend on etchant's temperature	etching rates depend on microwave power "pumped" into the solutions
hillocks formed in low concentration KOH or (and) low temperature	no hillocks
good anisotropy (10 M KOH ~ 40÷50) higher for stronger solutions	sufficient anisotropy 30÷20 higher for weaker solutions
batch process	single wafer process, batch process possible
long (hours)	short (< 60 minutes)
etching rates at 60°C negligible	etching rates at 60°C high (~ 5 μm/min)
etching rates in 3 M KOH negligible	etching rates in 3 M KOH high (~ 5 μm/min)
SiO ₂ , Si ₃ N ₄ mask	Si ₃ N ₄ mask only; selectivity 1:10000
60°C process impossible	60°C process good

Bezpieczeństwo użytkowania urządzeń mikrofalowych



1. Dyrektywa niskonapięciowa
2. Dyrektywa ciśnieniowa dot. Prostych zbiorników ciśnieniowych $pV < 10.000 \text{ bar cm}^3$
3. Dyrektyw kompatybilności EM ($P_r < 5 \text{ mW/cm}^2$)
4. Dokumentacja techniczna
5. Dokumentacja pomiarów i prób technicznych
6. Certyfikat CE producenta (lub/i -jednostki akredytowanej)



conductive heat

microwave heating

Fig. 1. Schematic of sample heating by conduction and microwave energy

ଓଜିଏମ୍ & ଏମ୍ ଛତ୍ର
 ଓଏମ୍